

Erratum: High power impulse magnetron sputtering: Current-voltage-time characteristics indicate the onset of sustained self-sputtering

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We noticed that Figures 1 and 2 of the original publication showed data of preliminary measurements that are not quite consistent with the text and figure captions.

We regret this mistake and provide here the correct figures.

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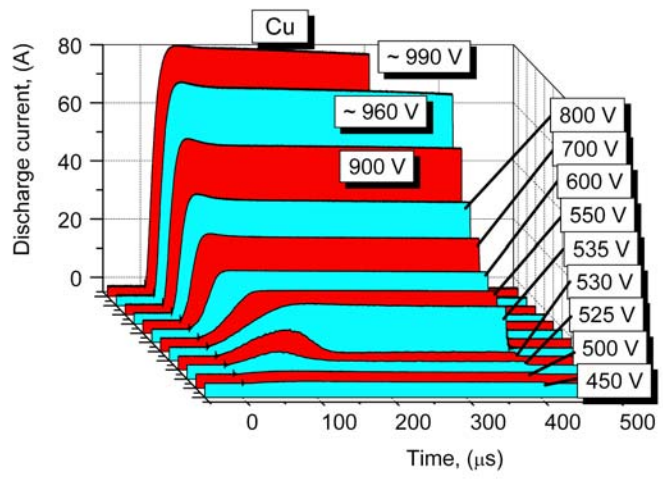


Fig. 1

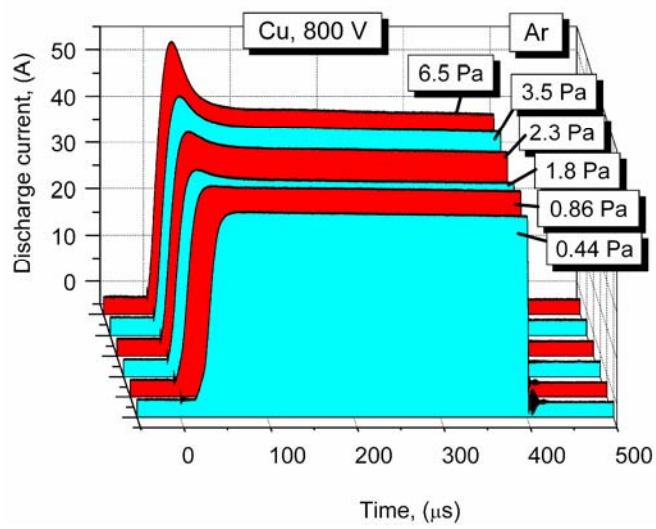


Fig. 2